Search Notes			

Application No.	Applicant(s)	
10/630,444	KOYANAGI ET AL.	
Examiner	Art Unit	
W David Coleman	2823	

SEARCHED			
Class	Subclass	Date	Examiner
438	240	9/30/2004	WDC
			-

INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner

SEARCH NOT (INCLUDING SEARCH)
	DATE	EXMR
EAST 1.4.1 Applicants claim forming a capacitor dielectric of ruthenium oxide using an ALD process	9/30/2004	WDC
Key words ALD capacitor dielectric hafnium oxide ruthenium	9/30/2004	WDC
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